

## PATENT ABSTRACTS OF JAPAN

(11)Publication number : 05-062189

(43)Date of publication of application : 12.03.1993

(51)Int.Cl.

G11B 7/00

B41M 5/26

G11B 7/24

(21)Application number : 03-219537

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(22)Date of filing : 30.08.1991

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## (54) REWRITABLE RECORDING MEDIUM AND ITS RECORDING METHOD

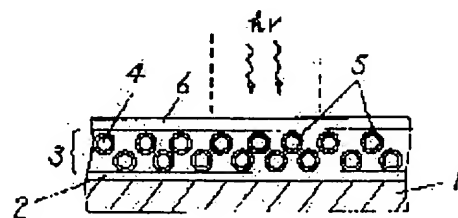
## (57)Abstract:

PURPOSE: To provide a recording medium wherein a recording operation and an erasing operation can be performed reversibly by means of light or heat by a recording layer wherein the following are contained: coloring particles whose surface is provided with a crystal nucleus formation ability as crystalline organic molecules; crystalline organic molecules; and a transparent matrix polymer.

CONSTITUTION: A polyester sheet provided with an aluminum vapor-deposited reflection layer 2 is used as a substrate 1. The reflection layer 2 is coated to a thickness of  $13\mu\text{m}$ , with a liquid in which the following are dispersed and dissolved in tetrahydrofuran:

hydroxystearic acid as crystalline organic molecules; a phenol-based antioxidant as an additive; a vinyl chloride-vinyl acetate copolymer as a transparent matrix polymer; and red glass beads in an average of  $15\mu\text{m}$  as coloring particles 4. Thereby, a recording layer 3 is formed. In

addition, a UV-curing acrylic resin is coated as a surface protective layer 6. The title recording medium becomes transparent at about 70 to 90°C, and its recording operation can be performed at 100°C by using a semiconductor laser. The recording durability of the recording medium amounts to about 600 times.



## LEGAL STATUS

[Date of request for examination]

13.03.1998

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the

examiner's decision of rejection or application  
converted registration]

[Date of final disposal for application]

[Patent number] 2993203

[Date of registration] 22.10.1999

[Number of appeal against examiner's decision of  
rejection]

[Date of requesting appeal against examiner's  
decision of rejection]

[Date of extinction of right]

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